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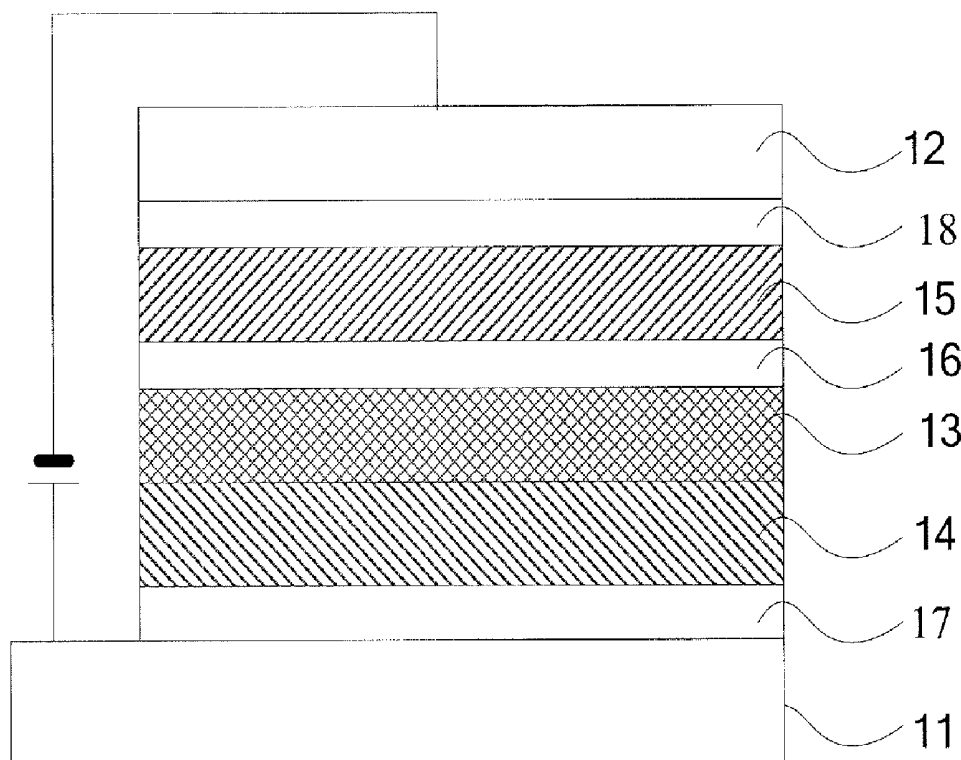
(19) **United States**(12) **Patent Application Publication**
Jiao(10) **Pub. No.: US 2015/0144894 A1**(43) **Pub. Date: May 28, 2015**(54) **ORGANIC LIGHT EMITTING DEVICE AND
DISPLAY DEVICE****Publication Classification**(71) Applicant: **BOE TECHNOLOGY GROUP CO.,
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51/0092 (2013.01); **H01L 51/5072** (2013.01)(73) Assignee: **BOE TECHNOLOGY GROUP CO.,
LTD.**, Beijing (CN)(21) Appl. No.: **14/347,866**(22) PCT Filed: **Nov. 13, 2013**(57) **ABSTRACT**(86) PCT No.: **PCT/CN13/87039**

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An organic light emitting device and a display device is provided. The organic light emitting device includes an anode, a cathode, and a light emitting layer disposed between the anode and the cathode; an electron transport layer disposed between the cathode and the light emitting layer, and the material of the electron transport layer is an organic metal chelate.



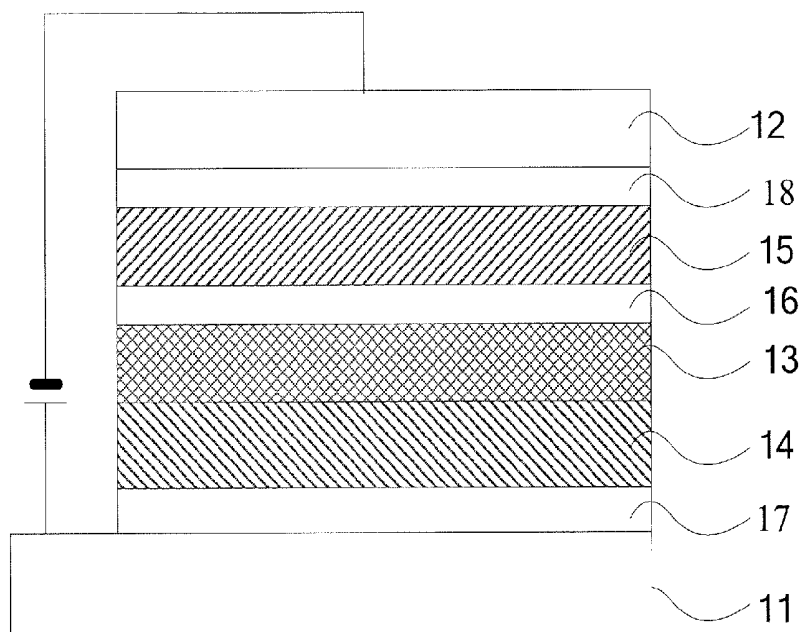


Fig. 1

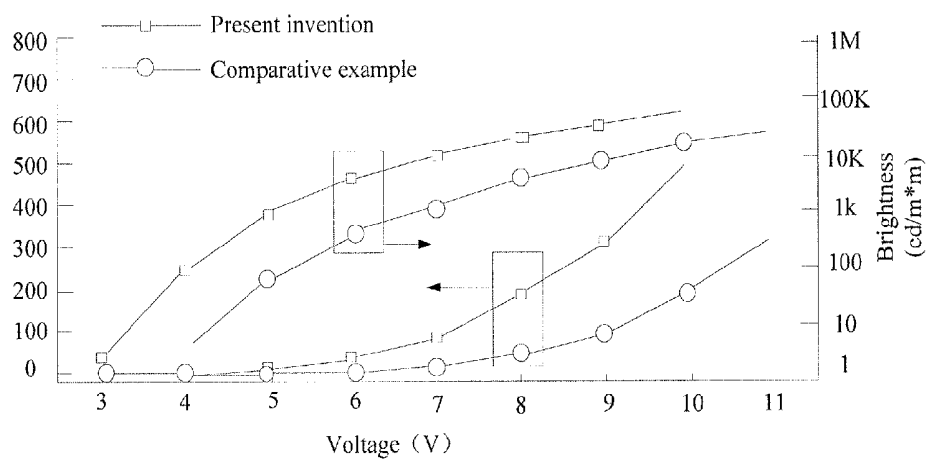


Fig. 2

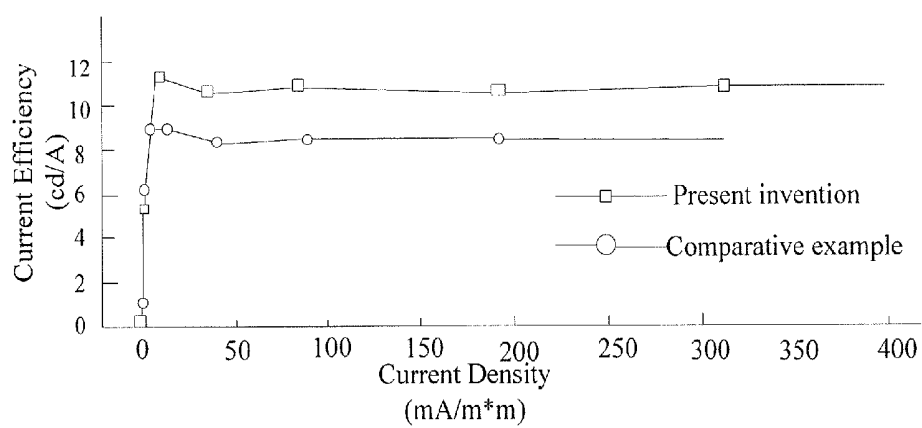


Fig. 3

ORGANIC LIGHT EMITTING DEVICE AND DISPLAY DEVICE

TECHNICAL FIELD

[0001] Embodiments of the present invention relate to an organic light emitting device and a display device.

BACKGROUND

[0002] An organic light emitting device (OLED) consists of a cathode, an anode, a hole transport layer disposed between the cathode and the anode, a light emitting layer and an electron transport layer. When a proper voltage is applied to the anode and the cathode, the holes generated at the anode and the electrons generated at the cathode are transported through the hole transport layer and the electron transport layer respectively and recombined in the light emitting layer, so that the light emitting layer emits lights of three primary colors RGB which constitute basic colors of light emitting device based on compositions of the light emitting layer.

[0003] If electron mobility of the electron transport layer is low or the energy barrier for the electron to be injected into the electron transport layer from the cathode is high, the number of the electrons in the light emitting layer of the OLED decreases, thus the number of holes is greater than the number of electrons, and the number of holes and the number of electrons do not match, which results in a low light emitting efficiency of the OLED.

SUMMARY

[0004] An embodiment of the present invention provides an OLED, comprising an anode, a cathode, and a light emitting layer disposed between the anode and the cathode; and an electron transport layer disposed between the cathode and the light emitting layer, and the material of the electron transport layer comprises an organic metal chelate.

[0005] In an example, the lowest unoccupied molecular orbital (LUMO) energy level of the organic metal chelate is $-4.2\text{ eV}\sim 3.0\text{ eV}$.

[0006] In an example, the highest occupied molecular orbital (HOMO) energy level of the organic metal chelate is greater than or equal to -6.0 eV , and a hole blocking layer is disposed between the light emitting layer and the electron transport layer.

[0007] In an example, the highest occupied molecular orbital (HOMO) energy level of the organic metal chelate is less than -6.0 eV , and the light emitting layer is in direct contact with the electron transport layer.

[0008] In an example, the lowest unoccupied molecular orbital (LUMO) energy level of the organic metal chelate is $-3.9\text{ eV}\sim 3.3\text{ eV}$.

[0009] In an example, the lowest unoccupied molecular orbital (LUMO) energy level of the organic metal chelate is greater than the lowest unoccupied molecular orbital (LUMO) energy level of the cathode and less than the lowest unoccupied molecular orbital (LUMO) energy level of the light emitting layer, and the absolute value of the difference between the lowest unoccupied molecular orbital (LUMO) energy level of the organic metal chelate and the lowest unoccupied molecular orbital (LUMO) energy level of the cathode is less than or equal to 1.2 eV .

[0010] In an example, the absolute value of the difference between the lowest unoccupied molecular orbital (LUMO)

energy level of the organic metal chelate and the lowest unoccupied molecular orbital (LUMO) energy level of the cathode is less than or equal to 0.9 eV .

[0011] In an example, the absolute value of the difference between the lowest unoccupied molecular orbital (LUMO) energy level of the organic metal chelate and the lowest unoccupied molecular orbital (LUMO) energy level of the cathode is less than or equal to 0.6 eV .

[0012] In an example, the organic metal chelate comprises CuPc or ZnPc.

[0013] In an example, the anode is a patterned indium tin oxide (ITO) layer.

[0014] In an example, the OLED further comprises a hole transport layer disposed between the anode and the light emitting layer; a hole injecting layer disposed between the anode and the hole transport layer, and an electron injecting layer disposed between the electron transport layer and the cathode.

[0015] In an example, the OLED has a stacked structure connected in series.

[0016] Another embodiment of the present invention provides a display device which comprises the above OLED.

[0017] The OLED and the display device provided in the embodiments of the present invention can significantly improve the electron injecting and transport efficiency of the OLED device by using a metal chelate as the material of the electron transport layer, and in turn can balance the numbers of the holes and electrons in the light emitting layer, and significantly improve the light emitting efficiency of the device.

BRIEF DESCRIPTION OF THE DRAWINGS

[0018] In order to clearly illustrate the technical solutions of the embodiments of the invention, the drawings of the embodiments will be briefly described in the following. It is obvious that the described drawings are only related to some embodiments of the invention and thus are not limitative of the invention.

[0019] FIG. 1 is a schematic sectional view of an OLED provided in an embodiment of the present invention;

[0020] FIG. 2 is a schematic graph of current density-voltage-brightness of two devices under different driving voltages; and

[0021] FIG. 3 is a schematic graph of current efficiency-current density of two devices under different current densities.

DETAILED DESCRIPTION

[0022] In order to make objects, technical details and advantages of the embodiments of the invention apparent, the technical solutions of the embodiment will be described in a clearly and fully understandable way in connection with the drawings related to the embodiments of the invention. It is obvious that the described embodiments are just a part but not all of the embodiments of the invention. Based on the described embodiments herein, those skilled in the art can implement other embodiment(s), without any creative work, which should fall within the scope of the invention.

[0023] The embodiment of the present invention provides an OLED, as shown in FIG. 1. The OLED comprises an anode 11, a cathode 12, and a light emitting layer 13 disposed between the anode 11 and the cathode 12; a hole transport layer 14 disposed between the anode 11 and the light emitting

layer **13**, and an electron transport layer **15** disposed between the cathode **12** and the light emitting layer **13**. The hole transport layer **14** is configured to transport holes generated at the anode **11** to the light emitting layer **13**, and the electron transport layer **15** is configured to transport electrons generated at the cathode **12** to the light emitting layer **13**. In the embodiments of the present invention, the material of the electron transport layer comprises an organic metal chelate.

[0024] The OLED provided in the embodiment of the present invention uses a metal chelate as the material of the electron transport layer so as to significantly improve electron injection and transport efficiency of the OLED device, and in turn balance the numbers of the holes and electrons in the light emitting layer, and significantly improve the light emitting efficiency of the device.

[0025] In an example, the lowest unoccupied molecular orbital (LUMO) energy level of the organic metal chelate is $-4.2\text{ eV}\sim 3.0\text{ eV}$, and the highest occupied molecular orbital (HOMO) energy level of the organic metal chelate is greater than or equal to -6.0 eV . In this case, the HOMO energy level of the organic metal chelate cannot effectively block the holes, thus, as shown in FIG. 1, a hole blocking layer **16** is disposed between the light emitting layer **13** and the electron transport layer **15**. Herein it is noted that the LUMO is an electron transport energy level, and the HOMO is a hole transport energy level.

[0026] In an example, the LUMO energy level of the organic metal chelate is $-4.2\text{ eV}\sim 3.0\text{ eV}$ and the HOMO energy level is less than -6.0 eV . In the case where the HOMO energy level of the organic metal chelate is less than -6.0 eV , due to strong ability of the electron transport layer to block the holes, it is not necessary to dispose the hole blocking layer, and the light emitting layer is in direct contact with the electron transport layer.

[0027] The LUMO energy level of the organic metal chelate is $-4.2\text{ eV}\sim 3.0\text{ eV}$. However, in order to form a proper energy level step between the cathode and the light emitting layer, the LUMO energy level of the organic metal chelate can be, for example, $-3.9\text{ eV}\sim 3.3\text{ eV}$; or $-3.8\text{ eV}\sim 3.4\text{ eV}$; or $-3.7\text{ eV}\sim 3.5\text{ eV}$; or -3.6 eV .

[0028] For example, the organic metal chelate can be CuPc, or ZnPc or the like.

[0029] For example, the anode is a patterned layer of indium tin oxide (ITO). Since the ITO used as the anode is patterned, such uneven surface of the ITO can avoid total reflection of lights which otherwise cannot emit out of the glass substrate due to such total reflection so as to enhance light output.

[0030] Optionally, as shown in FIG. 1, the OLED further comprises a hole injecting layer **17** disposed between the anode **11** and the hole transport layer **14**, and an electron injecting layer **18** disposed between the electron transport layer **15** and the cathode **12**.

[0031] For example, the anode **11** is a glass substrate with an ITO pattern. The hole injecting layer **17** can be made of a material of MoO_3 , F4-TCNQ or the like. The hole transport layer **14** can be made of a material of NPB, TPD or the like. The light emitting layer **13** can be made of an organic polymer, an organic fluorescent or phosphorescent monomer material, or the like, and the light emitting layer can be a monochromatic, hybrid-colored light emitting layer for example a white light emitting layer. The hole blocking layer **16** can be made of an electron transport type material with a low LUMO energy level such as BCP. The electron transport

layer **15** can be made of an organic metal chelate such as CuPc. The electron injecting layer **18** can be made of conventional electron injecting materials such as LiF, Liq, CsF or Cs_2CO_3 . The cathode **12** can be made of Al. Herein it is noted that the HOMO energy level of the electron transport layer CuPc is -5.2 eV (greater than -6.0 eV), thus, it is necessary to dispose the hole blocking layer **16** between the electron transport layer **15** and the light emitting layer **13** to block the holes.

[0032] In the embodiments of the present invention, a light emitting layer with a blue color is taken as an example. The blue light emitting layer has a body of MAND (2-methyl-9, 10-bis(naphthalen-2-yl) anthracene), and a dopant of DSA-Ph (1-4-di-[4-(N,N-diphenyl) amino]styryl-benzene). In an example, the anode is a patterned ITO layer with a thickness of 150 nm. The hole injecting layer is made of MoO_3 with a thickness of 5 nm. The hole transport layer is made of NPB with a thickness of 40 nm. The blue light emitting layer is made of MAND:DSA-Ph with a thickness of 30 nm. The hole blocking layer is made of BCP with a thickness of 10 nm. The electron transport layer is made of CuPc with a thickness of 35 nm. The electron injecting layer is made of LiF with a thickness of 1 nm. The cathode is made of Al with a thickness of 120 nm.

[0033] The fabricating method of the above OLED is described as following. A transparent glass substrate with an ITO layer with a sheet resistance less than $30\Omega/\square$ is subjected to a photolithography process to form a patterned ITO layer, then the glass substrate is cleaned sequentially with deionized water, acetone and absolute ethyl alcohol in an supersonic environment, then the cleaned substrate is blow-dried with N_2 and subjected to O_2 plasma treatment. Finally, the treated substrate is placed in an evaporation chamber. When the vacuum level is lower than $5\times 10^{-4}\text{ Pa}$, the hole injecting layer MoO_3 (5 nm), the hole transport layer NPB (40 nm), the blue light emitting layer MAND:DSA-Ph (3%) (30 nm), the hole blocking layer BCP (10 nm), the electron transport layer CuPc (35 nm), the electron injecting layer LiF (1 nm) and the cathode Al (120 nm) are sequentially deposited on the patterned ITO layer by a method of vacuum thermal evaporation. During the thermal evaporation, for deposition of all layers except Al, an open mask is employed at an evaporation speed of 0.1 nm/s. And for deposition of Al layer, a metal cathode mask is employed with an evaporation speed of 0.3 nm/s. The light emitting area of the device is 3 mm $\times$ 3 mm.

[0034] For comparison, a comparative example of an OLED is provided. The OLED has similar functional layers as the OLED having the electron transport layer of CuPc described above, except that the OLED in the comparative example has an electron transport layer made of Bphen and is not provided with the hole blocking layer (since the HOMO energy level of Bphen is -6.4 eV less than -6.0 eV , the holes can be sufficiently blocked and it is not necessary to have the hole blocking layer). The OLED having the electron transport layer of CuPc provided in an embodiment of the present invention is compared with the OLED having the electron transport layer of Bphen in the comparative example.

[0035] In the OLED provided in the comparative example using Bphen as the electron transport layer, the LUMO energy level of the cathode (Al) and the electron injecting layer (LiF) is about -4.2 eV , the LUMO energy level of the electron transport layer (Bphen) is about -2.9 eV , and the LUMO energy level of the light emitting layer (MAND:DSA-Ph) is about -2.5 eV . Thus the energy level step between the electron transport layer Bphen (-2.9 eV) and the electron

injection layer LiF (−4.2 eV) is so high that a relatively large driving voltage is needed. In the OLED provided in the embodiments of the present invention, the LUMO energy level of the cathode (Al) and the electron injecting layer (LiF) is about −4.2 eV, the LUMO energy level of the electron transport layer (CuPc) is about −3.6 eV, the LUMO energy level of the hole blocking layer (BCP) is about −3.2 eV, and the LUMO energy level of the light emitting layer (MAND: DSA-Ph) is about −2.5 eV. In this case, the electron transport layer of CuPc (−3.6 eV) provided in the embodiment of the present invention can fittingly form a proper electron transport energy level step between the electron injecting layer (−4.2 eV) and the hole blocking layer (−3.2 eV), and then the driving voltage can be effectively lowered.

[0036] More importantly, the electron mobility of CuPc can reach 9.04×10^{-4} cm²/Vs under an electric field of 3.0×10^5 V/cm, whereas the electron mobility of the current common electron transport material Bphen is 4.2×10^{-4} cm²/Vs under the electric field of 3.0×10^5 V/cm. Thus the electron transport ability of CuPc is better in comparison. That is, the OLED with CuPc as the electron transport layer has a better electron injection and transport efficiency.

[0037] The device provided in the embodiments of the present invention and the device provided in the comparative example are compared through experiments and measurements hereinafter, and FIGS. 2 and 3 are obtained from experiments and measurements. FIG. 2 is a graph of the current density-voltage-brightness of two devices under different driving voltages. FIG. 3 is a graph of the current efficiency-current density of two devices under different current densities. It can be seen from the graphs that, compared with the device using the Bphen as the electron transport layer, the current density and the brightness of the device provided in the embodiments of the present invention using CuPc as the electron transport layer are improved significantly, illustrating that the electron injection efficiency of the device has been enhanced significantly. In particular, the maximum brightness of the device is enhanced by 113.4% from 26700 cd/m² to 56980 cd/m², and the maximum current efficiency is enhanced by 26.2% from 8.98 cd/A to 11.3 cd/A. It can be seen that the device using CuPc as the electron transport layer has a greatly improved light emitting performance, compared with the device using Bphen as the electron transport layer.

[0038] In the above embodiment, a metal chelate is selected to form the electron transport layer and then a proper energy level step is formed between the cathode and the light emitting layer, and thereby the electron injection efficiency is enhanced. The LUMO value of the above metal chelate is optimized according to the LUMO energy levels of the cathode and the light emitting layer. For example, when the LUMO of the cathode or the electron injecting layer is −4.2 eV and the LUMO of the light emitting layer is −2.5 eV, a metal chelate whose LUMO is within the range of −4.2 eV~−3.0 eV can be selected. However, the cathode, the electron injecting layer and the light emitting layer according to the embodiments of the present invention are not limited to the above specific LUMO values. An embodiment according to the present invention further provides an OLED as following. The lowest unoccupied molecular orbital (LUMO) energy level of the organic metal chelate is greater than the lowest unoccupied molecular orbital (LUMO) energy level of the cathode and less than the lowest unoccupied molecular orbital (LUMO) energy level of the light emitting layer, and the absolute value of the difference between the lowest unoc-

cupied molecular orbital (LUMO) energy level of the organic metal chelate and the lowest unoccupied molecular orbital (LUMO) energy level of the cathode is less than or equal to 1.2 eV; or, the absolute value of the difference between the lowest unoccupied molecular orbital (LUMO) energy level of the organic metal chelate and the lowest unoccupied molecular orbital (LUMO) energy level of the cathode is less than or equal to 0.9 eV; or, the absolute value of the difference between the lowest unoccupied molecular orbital (LUMO) energy level of the organic metal chelate and the lowest unoccupied molecular orbital (LUMO) energy level of the cathode is less than or equal to 0.6 eV.

[0039] For example, the OLED in the embodiment of the present invention can have a stacked structure connected in series, and the OLED elements connected in series in the stack share a common electrode as their respective anode and cathode, and this can enhance the light emitting efficiency of the device and increase service life of the device.

[0040] The embodiment of the present invention further provides a display device comprising the above OLED, and the display device can be a product or a part having a display function, such as an OLED display, an OLED display panel, a digital camera, a mobile phone, a tablet computer or an electronic paper.

[0041] The above description is only the exemplary embodiments of the present invention and not intended to limit the protection scope of the present invention, which is defined by appending claims.

1. An organic light emitting device, comprising an anode, a cathode, and a light emitting layer disposed between the anode and the cathode; and

an electron transport layer disposed between the cathode and the light emitting layer, and the electron transport layer comprising a material of an organic metal chelate.

2. The organic light emitting device according to claim 1, wherein the organic metal chelate has a lowest unoccupied molecular orbital (LUMO) energy level of −4.2 eV~−3.0 eV.

3. The organic light emitting device according to claim 2, wherein the organic metal chelate has a highest occupied molecular orbital (HOMO) energy level greater than or equal to −6.0 eV, and a hole blocking layer is disposed between the light emitting layer and the electron transport layer.

4. The organic light emitting device according to claim 2, wherein the organic metal chelate has a highest occupied molecular orbital (HOMO) energy level less than −6.0 eV, and the light emitting layer is in direct contact with the electron transport layer.

5. The organic light emitting device according to claim 2, wherein the organic metal chelate has a lowest unoccupied molecular orbital (LUMO) energy level of −3.9 eV~−3.3 eV.

6. The organic light emitting device according to claim 1, wherein the organic metal chelate has a lowest unoccupied molecular orbital (LUMO) energy level greater than a lowest unoccupied molecular orbital (LUMO) energy level of the cathode and less than a lowest unoccupied molecular orbital (LUMO) energy level of the light emitting layer, and the absolute value of the difference between the lowest unoccupied molecular orbital (LUMO) energy level of the organic metal chelate and the lowest unoccupied molecular orbital (LUMO) energy level of the cathode is less than or equal to 1.2 eV.

7. The organic light emitting device according to claim 6, wherein the absolute value of the difference between the lowest unoccupied molecular orbital (LUMO) energy level of

the organic metal chelate and the lowest unoccupied molecular orbital (LUMO) energy level of the cathode is less than or equal to 0.9 eV.

8. The organic light emitting device according to claim 6, wherein the absolute value of the difference between the lowest unoccupied molecular orbital (LUMO) energy level of the organic metal chelate and the lowest unoccupied molecular orbital (LUMO) energy level of the cathode is less than or equal to 0.6 eV.

9. The organic light emitting device according to claim 1, wherein the organic metal chelate comprises CuPc or ZnPc.

10. The organic light emitting device according to claim 1, wherein the anode is a patterned indium tin oxide (ITO) layer.

11. The organic light emitting device according to claim 1, further comprising:

a hole transport layer disposed between the anode and the light emitting layer; a hole injecting layer disposed between the anode and the hole transport layer, and an electron injecting layer disposed between the electron transport layer and the cathode.

12. The organic light emitting device according to claim 1, wherein the organic light emitting device has a stacked structure connected in series.

13. A display device, comprising
an organic light emitting device comprising an anode, a cathode, a light emitting layer disposed between the anode and the cathode; and
an electron transport layer disposed between the cathode and the light emitting layer, and the electron transport layer comprising a material of an organic metal chelate.

14. The display device according to claim 13, wherein the organic metal chelate has a lowest unoccupied molecular orbital (LUMO) energy level of $-4.2\text{ eV} \sim -3.0\text{ eV}$.

15. The display device according to claim 14, wherein the organic metal chelate has a highest occupied molecular orbital (HOMO) energy level greater than or equal to -6.0 eV ,

and a hole blocking layer is disposed between the light emitting layer and the electron transport layer.

16. The display device according to claim 14, wherein the organic metal chelate has a highest occupied molecular orbital (HOMO) energy level less than -6.0 eV , and the light emitting layer is in direct contact with the electron transport layer.

17. The display device according to claim 14, wherein the organic metal chelate has a lowest unoccupied molecular orbital (LUMO) energy level of $-3.9\text{ eV} \sim -3.3\text{ eV}$.

18. The display device according to claim 13, wherein the organic metal chelate has a lowest unoccupied molecular orbital (LUMO) energy level greater than a lowest unoccupied molecular orbital (LUMO) energy level of the cathode and less than a lowest unoccupied molecular orbital (LUMO) energy level of the light emitting layer, and the absolute value of the difference between the lowest unoccupied molecular orbital (LUMO) energy level of the organic metal chelate and the lowest unoccupied molecular orbital (LUMO) energy level of the cathode is less than or equal to 1.2 eV.

19. The display device according to claim 18, wherein the absolute value of the difference between the lowest unoccupied molecular orbital (LUMO) energy level of the organic metal chelate and the lowest unoccupied molecular orbital (LUMO) energy level of the cathode is less than or equal to 0.9 eV.

20. The organic light emitting device according to claim 18, wherein the absolute value of the difference between the lowest unoccupied molecular orbital (LUMO) energy level of the organic metal chelate and the lowest unoccupied molecular orbital (LUMO) energy level of the cathode is less than or equal to 0.6 eV.

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摘要(译)

提供有机发光装置和显示装置。有机发光器件包括阳极，阴极和设置在阳极和阴极之间的发光层；电子传输层设置在阴极和发光层之间，电子传输层的材料是有机金属螯合物。

